# RENESAS

# GaAs MES FET **NE76000**

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CHIP DIMENSIONS (Unit:  $\mu$ m)

450

**◄** 57 ►

49 48

Thickness = 140 μm

225

# C to Ku BAND LOW NOISE AMPLIFIER N-CHANNEL GaAs MES FET

#### FEATURES

- Low noise figure NF = 1.6 dB TYP. at f = 12 GHz
- High associated gain
  Ga = 9.0 dB TYP. at f = 12 GHz
- Gate length:  $L_g = 0.3 \ \mu m$
- Gate width: W<sub>g</sub> = 280 μm

#### ABSOLUTE MAXIMUM RATINGS (TA = 25 °C)

Drain to Source Voltage	Vds	5.0	V
Gate to Source Voltage	Vgs	-3.0	V
Gate to Drain Voltage	Vgd	-5.0	V
Drain Current	lo	IDSS	mA
Total Power Dissipation	Ptot	500 <sup>*1</sup>	mW
Channel Temperature	Tch	175	°C
Storage Temperature	Tstg	-65 to +175	°C
Thermal Resistance	Rth(c-a)	190	°C/W

\***1**: T<sub>A</sub> = 100 °C

Ptot for chip mounted on a copper heat sink.

### ELECTRICAL CHARACTERISTICS (TA = 25 °C)

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CHARACTERISTIC	SYMBOL	MIN.	TYP.	MAX.	UNIT	TEST CONDITIONS
Gate to Source Leak Current	lgso			10	μA	$V_{GS} = -4 V$
Saturated Drain Current	IDSS	15	30	50	mA	$V_{DS} = 3 V$ , $V_{GS} = 0 V$
Gate to Source Cutoff Voltage	VGS(off)	-0.5	-0.8	-3.0	V	$V_{DS} = 3 V, I_{D} = 100 \mu A$
Transconductance	gm	30	40	70	mS	$V_{DS} = 3 V, I_{D} = 10 mA$
Noise Figure	NF		1.6	1.8	dB	V <sub>DS</sub> = 3 V, I <sub>D</sub> = 10 mA
Associated Gain	Ga	8.0	9.0		dB	f = 12 GHz

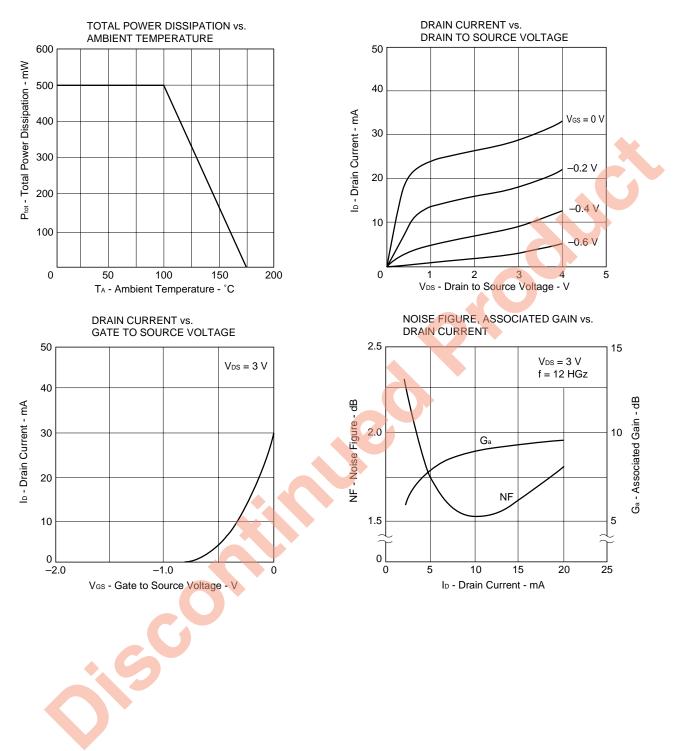
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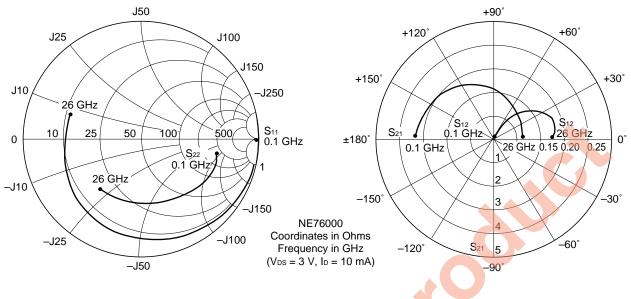
#### TYPICAL CHARACTERISTICS (TA = 25 °C)



# NEC

# **NE76000**

#### **S-Parameters**



#### Note: S-parameters include bond wires.

- Gate : Total 2 wire(s), 1 per bond pad, 0.0139" (354  $\mu$ m) long each wire.
- Drain : Total 2 wire(s), 1 per bond pad, 0.0115" (291  $\mu$ m) long each wire.
- Source : Total 4 wire(s), 2 per side, 0.0066" (168  $\mu$ m) long each wire.
- Wire : 0.0007" (17.8  $\mu$ m) Diameter, Gold.

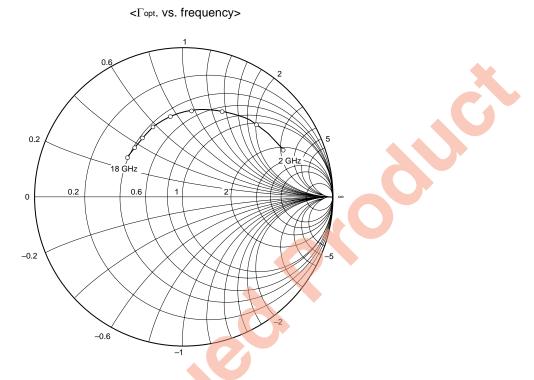
#### MAG AND ANG

 $V_{DS} = 3 V, I_{D} = 10 mA$ 

FREQUENCY(GHz)	S	511	S	21	S1:	2	9	S22	K	MAG
0.05	0.99	-1	3.32	180	0.001	89	0.68	-1	.15	35.2
0.10	0.99	-2	3.30	179	0.002	87	0.68	-1	.10	32.2
0.20	0.99	-3	3.29	178	0.004	86	0.68	-2	.10	29.2
0.50	0.99	-7	3.28	175	0.009	85	0.68	-3	.05	25.6
1.0	0.99	-14	3.27	169	0.02	81	0.67	-8	.05	21.9
2.0	0.99	-27	3.19	158	0.04	74	0.67	-16	.08	19.1
3.0	0.97	-39	3.08	148	0.06	66	0.66	-23	.13	17.3
4.0	0.95	-50	2.95	138	0.07	59	0.64	-30	.18	16.1
5.0	0.92	-61	2.81	129	0.09	51	0.62	-36	.24	15.2
6.0	0.89	-70	2.67	120	0.09	47	0.60	-42	.30	14.5
7.0	0.87	-78	2.55	113	0.10	41	0.59	-47	.34	13.9
8.0	0.86	-87	2.45	104	0.11	36	0.58	-53	.38	13.5
9.0	0.83	-96	2.33	97	0.11	30	0.57	-58	.45	13.1
10.0	0.81	-104	2.24	90	0.12	29	0.57	-63	.45	12.7
11.0	0.80	-112	2.16	83	0.13	23	0.56	-68	.48	12.3
12.0	0.77	-120	2.08	76	0.13	19	0.56	-73	.52	12.0
13.0	0.75	-128	2.00	70	0.13	16	0.55	-77	.56	11.9
14.0	0.74	-135	1.93	63	0.13	12	0.55	-81	.59	11.6
15.0	0.73	-141	1.85	58	0.13	9	0.55	-85	.62	11.4
16.0	0.72	-147	1.80	53	0.13	6	0.55	-88	.65	11.3
17.0	0.71	-152	1.73	47	0.13	5	0.55	-91	.72	11.3
18.0	0.70	-155	1.65	43	0.13	3	0.55	-94	.80	11.0
19.0	0.69	-159	1.57	38	0.12	2	0.55	-96	.97	11.1
20.0	0.68	-162	1.53	35	0.12	4	0.55	-99	.99	11.0
21.0	0.67	-166	1.49	30	0.12	5	0.55	-102	1.02	10.0
22.0	0.67	-171	1.46	26	0.12	4	0.55	-107	1.09	9.3
23.0	0.65	-176	1.41	21	0.12	5	0.55	-111	1.13	8.7
24.0	0.64	178	1.39	16	0.12	5	0.55	-116	1.08	8.9
25.0	0.63	171	1.32	11	0.12	5	0.55	-120	1.17	7.9
26.0	0.62	164	1.29	7	0.12	4	0.55	-123	1.18	7.6

#### NOISE PARAMETERS

 $V_{DS} = 3.0 V$  $I_D = 10 mA$ 



#### START 2 GHz, STOP 18 GHz, STEP 2 GHz

Freq.	NFmin.	Gain	Го	Rn/50		
(GHz)	(dB)	(dB)	MAG.	ANG.(deg.)		
2.0	0.65	18.0	0.76	25	0.63	
4.0	0.70	14.5	0.70	45	0.49	
6.0	0.85	12.5	0.64	65	0.41	
8.0	1.10	11.0	0.60	83	0.36	
10.0	1.30	9.9	0.56	99	0.32	
12.0	1.60	9.0	0.52	114	0.27	
14.0	1.90	8.2	0.49	125	0.23	
16.0	2.20	7.5	0.48	135	0.20	
18.0	2.50	7.0	0.47	145	0.18	

#### <Noise Parameter>

 $\Gamma_{\text{opt.}}$  includes bond wired.

Bond wires used during testing. Wire: 0.0007" (17.8  $\mu$ m) Diameter, Gold. Gate: 2 wires total, 1 per bond pad, 0.0139" long each wire. Drain: 2 wires total, 1 per bond pad, 0.0115" long each wire. Source: 4 wires total, 2 per side, 0.0066" long each wire.

#### CHIP HANDLING

#### **DIE ATTACHMENT**

Die attach operation can be accomplished with Au-Sn (within a 300  $^{\circ}$ C –10 s) performs in a forming gas environment.

Epoxy die attach is not recommend.

#### BONDING

Bonding wires should be minimum length, semi hard gold wire (3-8 % elongation) 20 microns in diameter.

Bonding should be performed with a wedge tip that has a taper of approximately 15 %. Bonding time should be kept to minimum.

As a general rule, the bonding operation should be kept within a 280 °C, 2 minutes for all bonding wires. If longer periods are required, the temperature should be lowered.

#### PRECAUTIONS

The user must operate in a clean, dry environment. The chip channel is glassivated for mechanical protection only and does not preclude the necessity of a clean environment.

The bonding equipment should be periodically checked for sources of surge voltage and should be properly grounded at all times. In fact, all test and handling equipment should be grounded to minimize the possibilities of static discharge.

Avoid high static voltage and electric fields, because this device is GaAs field effect transistor with shottky barrier gate.



The Great Care must be taken in dealing with the devices in this guide. The reason is that the material of the devices is GaAs (Gallium Arsenide), which is designated as harmful substance according to the law concerned. Keep the law concerned and so on, especially in case of removal.

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